

Differential Conductance of Magnetic Tunnel Junctions

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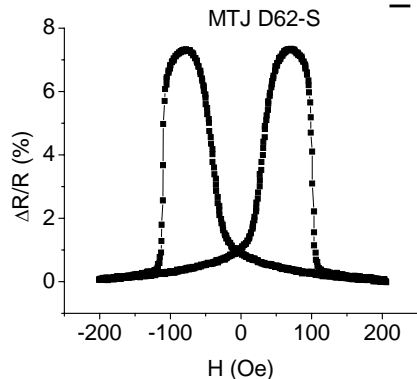
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NNIN Facility utilized: Characterization Facility & Nanofabrication Center

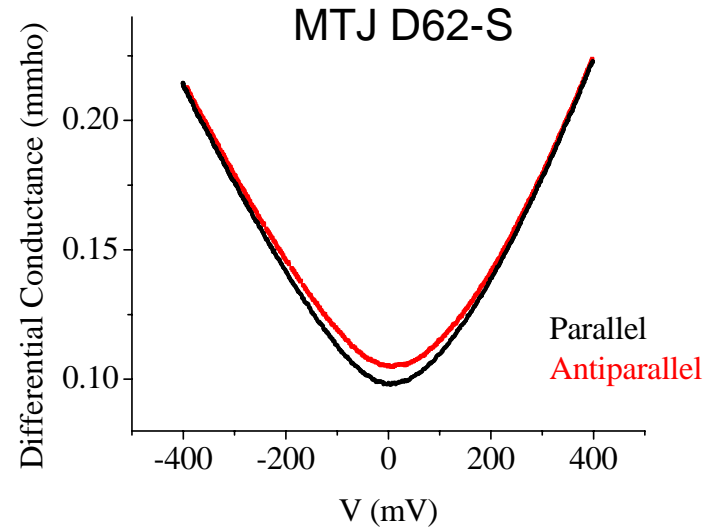
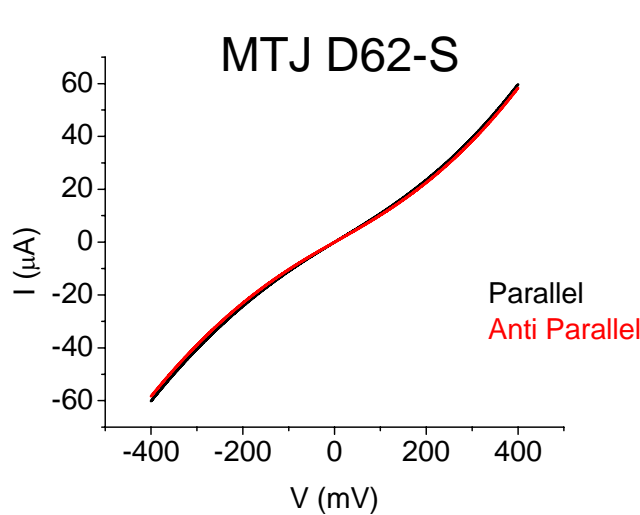
Magnetic tunnel junctions (MTJs) are comprised of two ferromagnetic layers separated by a thin insulating tunnel barrier. They are seeing widespread use in industry in magnetic sensor and data storage applications. Magnetic tunnel junctions are being fabricated in order to understand the bias voltage dependence of these devices and to use as spin injectors and detectors to measure spin diffusion lengths.

Ni ₈₁ Fe ₁₉ (20nm)
Co ₉ Fe (3nm)
AlO _x (~2nm)
Co ₉ Fe (5nm)
Substrate

MTJ structure



Magnetic tunnel junctions show a variable resistance as a function of magnetic field.



The IV curves are non-linear and the dI/dV curves are consistent with the Simmons model of a parabolic differential conductance.